Magnetic properties of epitaxial Fe_3O_4 films with various crystal orientations and TMR effect in room temperature

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Fe₃O₄ is a ferrimagnetic spinel ferrite that exhibits electric conductivity at room temperature (RT). Although the material has been predicted to be a half metal according to ab-initio calculations, magnetic tunnel junctions (MTJs) with Fe₃O₄ electrodes have demonstrated a small tunnel magnetoresistance effect. Not even the sign of the TMR ratio has been experimentally established. Here, we report on the magnetic properties of epitaxial Fe₃O₄ films with various crystal orientations. The films exhibited apparent crystal orientation dependence on hysteresis curves. In particular, Fe₃O₄(110) films exhibited in-plane uniaxial magnetic anisotropy. With respect to the squareness of hysteresis, Fe₃O₄ (111) demonstrated the largest squareness. Furthermore, we fabricated MTJs with Fe₃O₄(110) electrodes, and obtained an TMR effect of -12% at RT. The negative TMR ratio corresponded to the negative spin polarization of Fe₃O₄ predicted from band calculations.

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Half metals that have 100% spin polarization (P) at the Fermi level are key materials to fabricate spintronic devices because their high spin polarization enables very large magnetoresistance effects. The most impressive case is in magnetic tunnel junctions (MTJs) with epitaxial MgO tunnel barriers^{1,2}. As transport in MgO-MTJs is dominated by coherent tunneling of Δ_1 electrons with 100% spin polarization, the TMR ratio has reached 600% at RT³. Such a large TMR ratio has allowed us to fabricate highly functional spintronic devices like magnetoresistive random access memories (MRAMs). However, MTJs with MgO have stringent limitations where the crystal orientation should be bcc (001) due to band structure matching between MgO and the electrodes. Half metal is the solution to large TMR ratios without restricting the crystal structure or orientation. Thus far, many oxide materials have been proposed as candidates for half metals, e.g., CrO_2^4 , $La_{0.7}Sr_{0.3}MnO_3^5$, and $Fe_3O_4^6$. Of these materials, Fe₃O₄ has been considered to be the most promising as a half metal because of its high Curie temperature of 858 K, which is an advantage in applications to spintronic devices that require high Tc. The crystal structure is an inverse spinel with $\mathrm{Fe^{3+}}$ cations occupying tetrahedral sites (A sites) and Fe³⁺ and Fe²⁺ cations occupying octahedral sites (B sites). The magnetic couplings between A and B sites are antiferromagnetic and the couplings at A-A or B-B are ferromagnetic; consequently, it is a ferrimagnetic material. As Fe₃O₄ exhibits good electric conductivity at RT due to the hopping of electrons between $\mathrm{Fe^{2+}}$ and $\mathrm{Fe^{3+}}$ on the B sites⁷, the conduction electrons are 100% spin polarized. As hopping is frozen on cooling, conductivity greatly decreases at low temperature, which is known as Verwey transition. The transition temperature, T_v , is 120K⁸. The saturation magnetization of bulk Fe₃O₄ is 510 emu/cc⁹. According to Julliere's formula¹⁰, MTJs with Fe₃O₄ electrodes are expected to exhibit very high TMR ratios due to large spin polarization. To date, researchers have fabricated MTJs with Fe₃O₄ and measured magnetoresistance; however, the TMR ratios have been small. Although the reason for this is not completely understood, such small TMR ratios can be attributed to imperfect antiparallel magnetic states in MTJs¹¹. The magnetization process of Fe₃O₄ films should be improved to achieve clear parallel and antiparallel magnetic configurations. We prepared epitaxial Fe₃O₄ films with various crystal orientations, and investigated their crystalline qualities and magnetic properties. We also fabricated MTJs with Fe₃O₄ electrodes and observed a negative TMR effect of -12%.

The Fe₃O₄ thin films were prepared with three crystal orientations of (001), (110), and

- (111) by using a molecular beam epitaxy (MBE) system. The sample structures were:
- 1) an MgO(001) substrate/ $MgO(20 \text{ nm})/Fe_3O_4(60 \text{ nm})$,
- 2) an MgO(110) substrate/MgO (20 nm)/Fe₃O₄ (60 nm), and
- 3) an $Al_2O_3(0001)$ substrate/Pt (20 nm)/Fe₃O₄ (60 nm).

Following the deposition of MgO or Pt buffer layers, Fe₃O₄ thin film was formed by reactive deposition at a temperature (T_{sub}) of 300°C in an O₂ atmosphere of 4×10^{-4} Pa. Then, the films were annealed at 600°C for 30 min in an O₂ atmosphere. The partial pressure of O₂ gas was 1×10^{-4} Pa during annealing. All the samples were fabricated under the same growth conditions to enable the quality of Fe₃O₄ films to be compared. Epitaxial growth was observed with reflection high energy electron diffraction (RHEED) and the surface morphology was observed with atomic force microscopy (AFM). We also investigated the magnetization process at RT with a vibrating sample magnetometer (VSM).

Figs. 1 (a) and (b) show the RHEED patterns of Fe₃O₄(100) before and after O₂ annealing at 600°C for 30 min. The electron beam was incident along [100]. Fig. 1 (c) is an atomic force micrograph (AFM) of Fe₃O₄(100) after annealing. A streak RHEED pattern can be observed in Fig. 1 (a) meaning the Fe₃O₄ film grew epitaxially. In addition, p(1x1) surface reconstruction was observed¹²¹³. The streak pattern sharpened after annealing at 600°C in the O₂ atmosphere, as can be seen from Fig. 1 (b). A step-terrace structure can be confirmed from the AFM in Fig. 1 (c). The roughness average, R_a, was 0.12 nm, and the terrace width was 200 nm.

Figs. 1 (d)-(f) show the RHEED patterns and AFMs of Fe₃O₄(110) grown on MgO(110). The incident electron beam direction was [-110]. A spotty pattern was obtained before annealing due to the island growth of Fe₃O₄ (110). However, the surface flatness was improved dramatically by O₂ annealing at 600°C, as can be seen from the RHEED pattern in Fig. 1 (e). The surface in the AFM of Fe₃O₄(110) after annealing in Fig. 1 (f) had anisotropic shapes along [100], which seemed to originate from the anisotropy of the MgO(110) substrate. R_a was estimated to be 0.39 nm.

Finally, Figs. 1 (g)-(i) show RHEED patterns and AFMs of Fe₃O₄(111). The direction of the incident electron beam was [11-20]. Fig. 1(g) shows RHEED patterns of as-deposited Fe₃O₄(111). It shows streak patterns that indicate a flat surface and surface reconstruction. Terrace and step structures can be observed in the AFM of Fe₃O₄(111) after annealing in Fig. 1 (i); however, islands with a diameter of 200 nm and height of several tens of nanometers

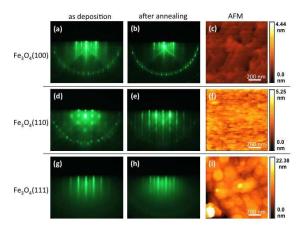


FIG. 1. RHEED patterns and AFMs of epitaxial Fe₃O₄ (60 nm) films. RHEED patterns were taken after deposition at 300°C and annealing at 600°C. AFM observations were carried out after annealing. (a), (b), and (c) are for MgO(100)/Fe₃O₄(100) (60 nm). (d), (e), and (f) are for MgO(110)/Fe₃O₄(110) (60 nm). (g), (h), and (i) are for Al₂O₃(0001)/Pt(111) (20 nm)/Fe₃O₄(111) (60 nm).

were observed on the surface (not shown) in the AFM of a large area. The R_a was estimated at 2.40 nm, which was one order of magnitude larger than the other crystal orientations. The large roughness could be attributed to the lattice mismatch between Fe_3O_4 and the Pt buffer layer¹⁴. As the lattice constant of Fe_3O_4 was 0.8397 nm and that of MgO was 0.421 nm, the lattice mismatch was about 0.3%. However, as the lattice constant of Pt was 0.392 nm, Fe_3O_4 lattice mismatch to the Pt buffer layer was 6.6%. Such large lattice mismatch could give rise to a larger surface roughness for $Fe_3O_4(111)$ than that for $Fe_3O_4(100)$.

The magnetization curves at RT for the Fe₃O₄ films are plotted in Fig. 2. The magnetic field was applied in plane. The diamagnetic components of the substrates were subtracted under the assumption that the magnetizations of the Fe₃O₄ were saturated at 5 kOe, which is the maximum field of VSM. The magnetization curve of Fe₃O₄ (100) is in Fig. 2 (a). The saturation magnetization (M_s) was 330 emu/cc, the remanent magnetization (M_r) was 100 emu/cc, and the coercive field (H_c) was 80 Oe. The remanent magnetization ratio (M_r/M_s) was 0.30. Fig. 2(b) plots the magnetization curves of Fe₃O₄ (110) where the directions of the magnetic field were [001] and [-110]. The saturation magnetization was 185 emu/cc for both magnetic field directions. M_r, H_c, and M_r/M_s in the magnetic field along [001] were

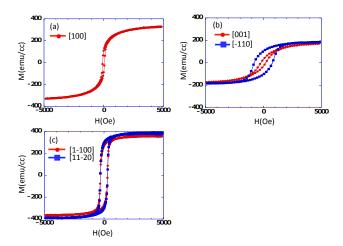


FIG. 2. Hysteresis curves obtained from VSM measurements at RT for epitaxial Fe₃O₄ films with various crystal orientations. (a) is Fe₃O₄(100), (b) is Fe₃O₄(110), and (c) is Fe₃O₄(111). Directions of magnetic fields are given in plots.

30 emu/cc, 210 Oe, and 0.16, and those for [-110] were 100 emu/cc, 780 Oe, and 0.54. The magnetization process strongly depended on the directions of the magnetic field, viz., the squareness and M_r/M_s were larger for the [-110] magnetic field than those for [100]. Nevertheless, the films had an anisotropic shape along the [100] direction, as shown in Fig. 1(f), and the films had a larger remanent ratio in the [-110] direction. Therefore, the anisotropy in Fig. 2 (b) was attributed to the magneto-crystalline anisotropy in Fe₃O₄. Saturation magnetization was 390 emu/cc, remanent magnetization was 290 emu/cc, and coercivity was 300 Oe in the magnetization curve of Fe₃O₄ (111). The remanent magnetization ratio was approximately 0.74, which was the largest value in the three crystal directions. The magnetic process was almost independent of the field directions. These values are summarized in Table 1. All the films exhibited smaller saturated magnetizations than the value for bulk Fe₃O₄ of 510 emu/cc. The reason for this is that the external field was not sufficient to saturate the magnetic moments in the Fe₃O₄ films. According to previous studies, Fe₃O₄ thin films contain considerable numbers of antiphase boundaries (APBs)¹⁵ that make the Fe₃O₄ hard to saturate magnetically due to antiferromagnetic coupling at the APBs.

We fabricated the MTJs with Fe₃O₄(110) electrodes, and measured the tunnel magnetoresistance effect. The film structure was MgO(110)/NiO(110) (5 nm)/Fe₃O₄(110) (60 nm)/Al₂O₃ (2.4 nm)/Fe (5 nm)/Co (10 nm)/Au (30 nm). The NiO layer was inserted to suppress the diffusion of Mg from the substrates. Junctions of $10 \times 10 \mu m^2$ were fabricated

TABLE I. Magnetic characteristics of Fe₃O₄ films with various crystal orientations.

	Ms	Mr	Нс	Mr/Ms
	(emu/cc)	(emu/cc)	(Oe)	
$Fe_3O_4(100)$	330	100	80	0.30
$Fe_3O_4(110) H//[001]$	185	30	210	0.16
$Fe_3O_4(110) H//[-110]$	185	100	780	0.54
$Fe_3O_4(111)$	390	290	300	0.74

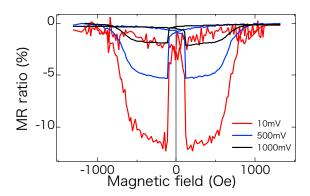


FIG. 3. TMR curve for MTJ of MgO(110)/NiO(110) (5 nm)/Fe₃O₄(110) (60 nm)/Al₂O₃ (2.4 nm)/Fe (5 nm)/Co (10 nm)/Au (30 nm) at RT. Red, blue, and black lines are TMRs with bias voltages of 10, 500, and 1000 mV.

by photolithography, Ar ion milling, and sputtering. The junctions demonstrated a clear TMR effect of -12% at RT, as shown in Fig. 3. The negative MR agreed with the ab-initio calculations that predicted negative spin polarization in Fe₃O₄. To the best of our knowledge, these are the first experimental results of a negative MR ratio with an AlO barrier and Fe₃O₄ electrodes¹⁶¹⁷¹⁸¹⁹²⁰. The polarization of Fe₃O₄ deduced from the MR ratio based on Julliere's formula was -16%, in which the polarization of Fe/Al₂O₃ was assumed to be $40\%^{21}$. Although the polarization was much smaller than the predicted value, -16% is of the same order as the reported values using various barrier materials²²²³.

 Fe_3O_4 epitaxial films with various crystal orientations were fabricated by reactive MBE and all the films grew epitaxially. The Fe_3O_4 (110) films exhibited clear uniaxial magnetic anisotropy that originated from crystal anisotropy. The squareness of the hysteresis curves strongly depended on the crystal orientation. A negative MR ratio of -12% was observed in

the MTJs with $Fe_3O_4(110)$ electrodes. Although the absolute value was small, the negative MR agreed with the theoretical predictions.

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